## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re A	Application of:	)		
	Kenro NAKAMURA, et al.	)	Group Art Unit: 1765	
Application No. 09/453,831		)	Examiner: Umez-Eronini, Lynette T.	
Filed:	December 2, 1999	) )	Confirmation No. 3119	Enter Amendmen
For:	POLISHING METHOD AND POLISHING LIQUID	) )		L.J.W.E.
Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450			11/14/2007	

## AMENDMENT AFTER DECISION ON APPEAL

After the Decision on Appeal of the Board of Patent Appeals and Interferences dated September 28, 2007, Applicants file this Amendment to place the application in condition for allowance, in accordance with the provisions discussed in M.P.E.P. § 1214.07. Accordingly, Applicants respectfully request that the application be amended as follows:

Amendments to the Claims are reflected in the listing of claims beginning on page 2 of this paper.

Remarks begin on page 4 of this paper.

Sir: